

corrosion resisting film. The corrosion resisting film is formed of a physically evaporated film. The photocatalytic film is formed by being treated with a coating material composition containing the metal oxide and an adhesive resin. The solid content adhesion quantity of the metal oxide is set to 0.5-10 g/m², and the solid content adhesion quantity of the adhesive resin is set to 0.1-0.9 g/m².

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